

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Seitaro Matsuo et al.

Application No.: 10/510,479
For: ECR PLASMA SOURCE AND ECR
PLASMA DEVICE

Confirmation No.: 7443
Filed: October 8, 2004
Art Unit: 1763
Examiner: R. K. Dhingra

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

In response to the Office Action dated January 11, 2007, please amend the above-identified U.S. patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 5 of this paper.